Research and Development Section
Indian Institute of Technology Guwahati
Guwahati-781039, Assam

Applications are invited for **Online Interview** for the **contractual post** of **Junior Research Fellow** (**JRF**) in a DST sponsored project entitled, "**Prototype Development of Low-cost Resistive Humidity Sensor**" at the Department of Electronics and Electrical Engineering, IIT Guwahati.

Date: 18th December 2023 (Monday)
Time: 10:00 AM
Venue: Online

Sl. No.	Project Staff Designation	Number of Vacancies	Pay Recommended (Rs.)	HRA Required (Rs.)	Medical Required (Rs.)	Total Amount (Rs.)	Duration of Appointment in months	Qualifications
1	JRF (GATE/ NET)	1	37000	Yes 18% Rs. 6660	0	43660	11	Candidates with a minimum B.E/ B.Tech. in Electrical/Electronics/Material Science and Engineering/ Materials/ Metallurgical Engineering/ Nanotechnology/ Chemical Engineering and its equivalent with GATE score or Higher Qualification (PhD/MTech/ME) in Electrical/Electronics/Material Science and Engineering/ Materials/ Metallurgical Engineering/ Nanotechnology/ Chemical Engineering and its equivalent may be considered as equivalent to B.E./B.Tech with GATE Score.

How to apply: The candidates have to send their CV giving details of all educational qualifications, experience, postal address, mobile no., email id, etc. along with all testimonials, **by 11:59 PM 16th December 2023 (Saturday),** to the Principal Investigator (PI) at the following email address with subject line **"Application for JRF Position, December 2023".** Shortlisted candidates will be called for online interview through e-mail which will also contain the interview schedule and Microsoft Teams link.

Selection process: The shortlisted candidates have to appear in the online interview. Selection committee will decide the suitable candidate after the interview.

For any clarification, contact: Dr. Ravindra Kumar Jha (Principal investigator)
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Phone: 0361-258-3462
Website: NSD Lab, IIT Guwahati

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